





irst Electrically Pumped Hybrid Silicon Laser

Sept 18th 2006

The information in this presentation is under embargo until 9/18/06- 10:00 AM PST



Agenda

Dr. Mario Paniccia

Director, Photonics Technology Lab

Dr. John Bowers

Professor, UC Santa Barbara

- What We are Announcing
- Silicon Photonics Overview
- Lasers & Light Emission with Silicon Photonics
- Joint Collaboration Hybrid Silicon Laser
- Hybrid Silicon Laser Test Results
- Summary





What We are Announcing

- Research Breakthrough: 1st Electrically pumped Hybrid Silicon Laser
 - A joint collaboration between UCSB and Intel Corporation
 - Combines the light emitting capabilities of Indium phosphide with the high volume, low cost capabilities of silicon
 - Addresses one of the last major hurdle to silicon photonic chips

Vision:

- Build chips containing 10 to 100s of Hybrid Silicon Lasers
- Built using high-volume, low cost manufacturing processes
- Enables terabit optical links

Background

- Silicon is a poor light emitter while Indium phosphide based materials are great light emitters
- However, Indium phosphide lasers are expensive to manufacture
- Novel design combined with a manufacturing process where a unique "glass glue" was used to bond the two materials together





The Photonic Dilemma

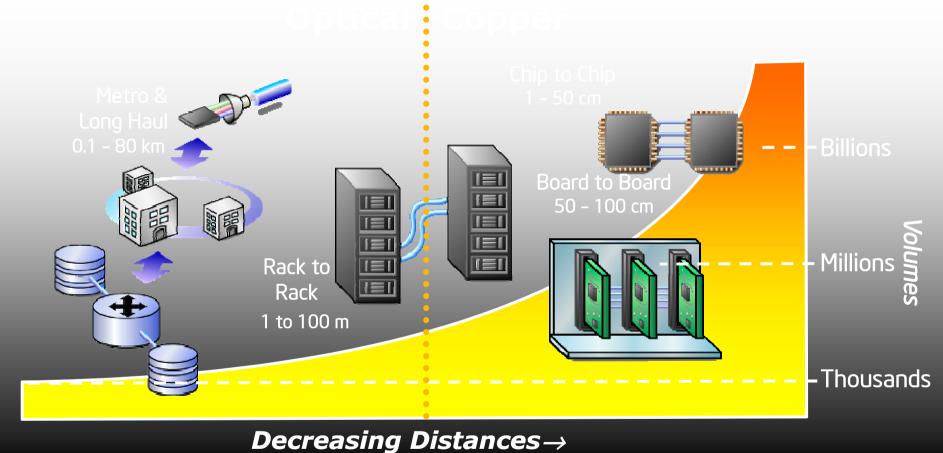
Fiber can carry much more bandwidth than copper

However, it is much more expensive.....





Today's High Speed Interconnects



Goal: Drive optical to high volumes and low costs





<u>Photonics:</u> The technology of emission, transmission, control and detection of light (photons) aka fiber-optics & opto-electronics

<u>Today:</u> Most photonic devices made with exotic materials, expensive processing, complex packaging

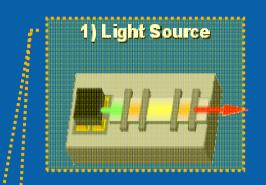
Silicon Photonics Vision: Research effort to develop photonic devices using silicon as base material and do this using standard, high volume silicon manufacturing techniques in existing fabs

Benefit: Bring volume economics to optical communications

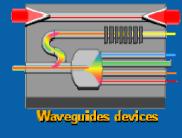


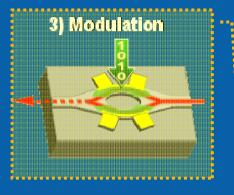


Intel's Silicon Photonics Research



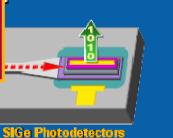
2) Guide Light



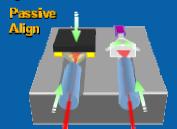


Continuous Wave Silicon Raman Laser (Feb '05)

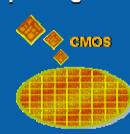
Photo-detection



5) Low Cost Assembly



6) Intelligence



1GHz (Feb '04) 10 Gb/s (Apr '05)

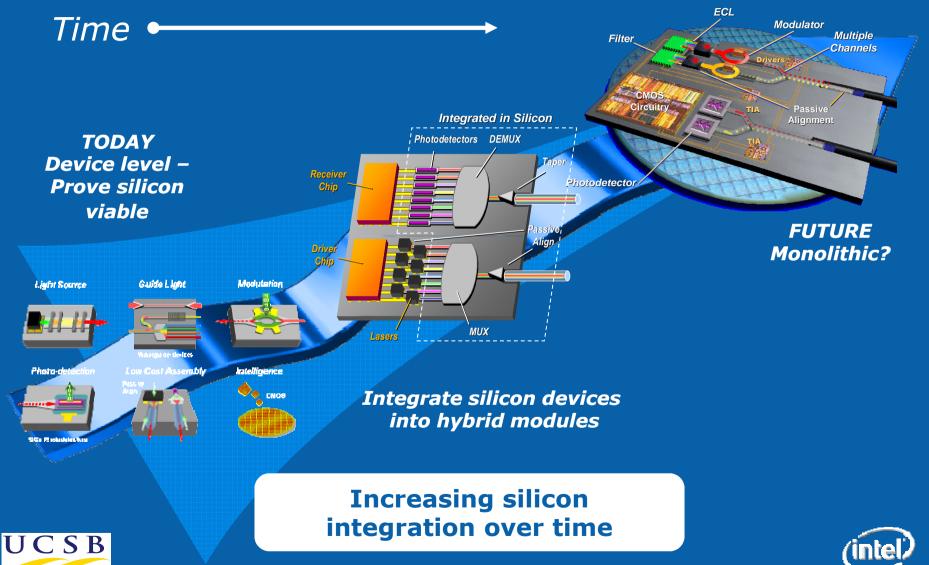
Pumped
Hybrid
Silicon laser
(September 2006)

First: Innovate to prove silicon is a viable optical material





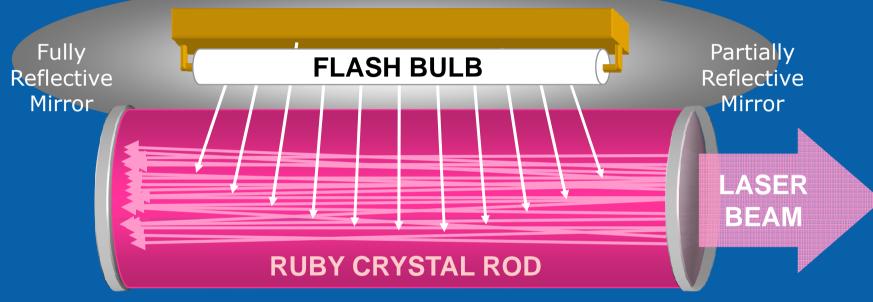
Integration Vision

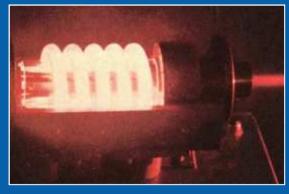




The First Laser

Developed by Maiman, this ruby laser used a flash bulb as an optical pump





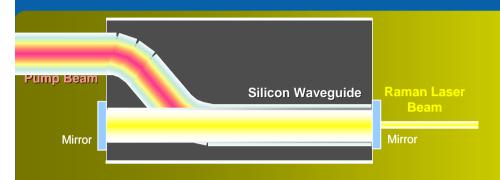




Published in *Nature*, August 6, 1960



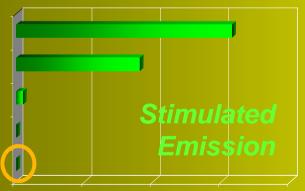
Raman Laser Announced in Feb 2005



First CW silicon laser

- Research Breakthrough
- •Based on the Raman effect
- Optically pumped

Radiative recombination coefficient (10-12cm3/s)



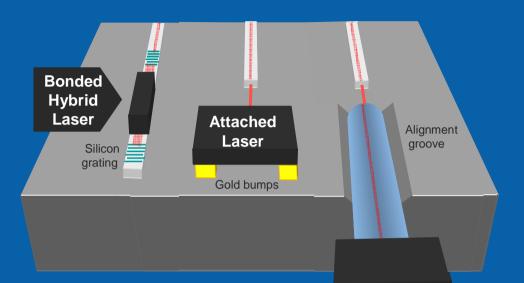
Want: Electrically Pumped

- Silicon is an indirect bandgap material
- Poor radiative recombination coefficient
- Result: Silicon emits heat, few photons





Options for Integrating Light Sources



Hybrid Silicon Laser

- Bond InP based material to Silicon
- No alignment
- Many lasers with one bonding step
- Amenable to high integration
- Potentially lowest cost

Off-chip laser

Direct Attached Laser

- Tight alignment tolerances
- Requires gold metal bonding
- Passive alignment challenges
- Less Expensive

Off-chip Laser

- High power laser required
- Requires fiber attach
- Non-integrated solution
- Expensive





Joint Intel / UCSB Collaboration

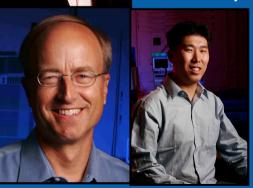
- Goal: Create a hybrid silicon laser
- Combine the light emitting properties of Indium phosphide with light routing and manufacturability properties of silicon

Joint team and 3 year research grant



UCSB – Indium phosphide and wafer bonding expertise

- Alex Fang (ex Intel intern)
- Professor John Bowers
- Hyundai Park



Intel – Silicon and manufacturing expertise

- Dr Richard Jones
- Oded Cohen
- Dr Mario Paniccia

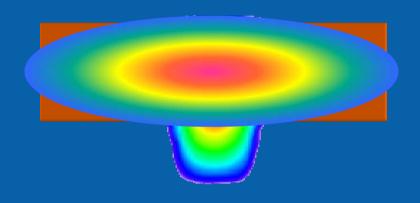




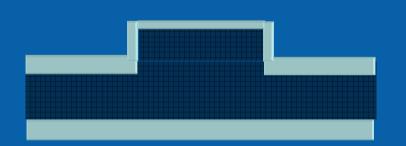




Hybrid Silicon Laser Using Evanescent Coupling



- •We start with a cross sectional view of an Indium Phosphide waveguide
- When a voltage is applied to the InP it will begin to emit light



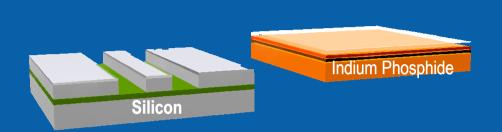
- •If we bring a silicon waveguide up to the InP, light will couple into the Si waveguide
- This is evanescent coupling

Challenge: How do you bond these two materials together?





Bonding Process



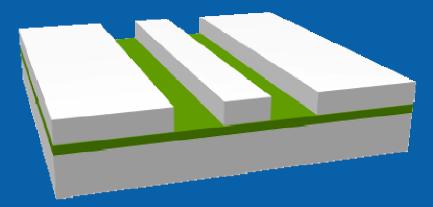
The Hybrid Silicon Laser used a unique bonding technique

- Previous attempts used crystal growth
 - Difficult to overcome lattice mismatch/threading dislocation
 - Causes poor performance
- Benefits of the UCSB/Intel approach
 - Removes issue with lattice mismatch
 - Plasma process produces ~25 atom thick "glass-glue"
 - This "glass-glue" efficiently bonds the two materials
 - Low temperature manufacturable process





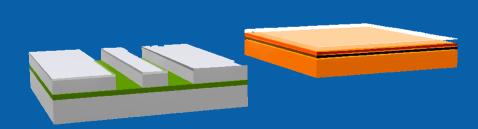
Process Animation



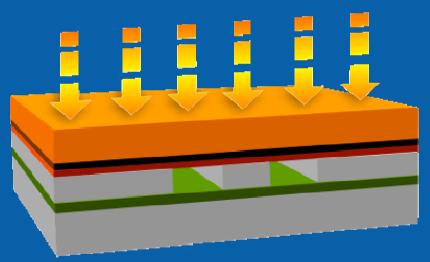
1) A waveguide is etched in silicon



2) The Indium phosphide is processed to make it a good light emitter



3) Both materials are exposed to the oxygen plasma to form the "glass-glue"

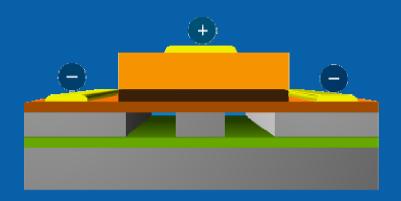


4) The two materials are bonded together under low heat

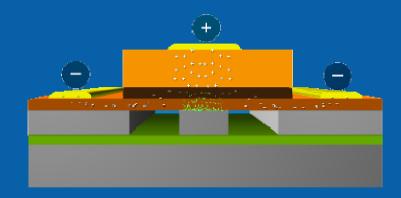




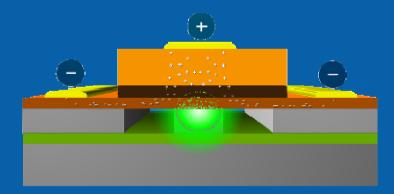
Process Animation



5) The Indium phosphide is etched and electrical contacts are added



6) Photons are emitted from the Indium Phosphide when a voltage is applied



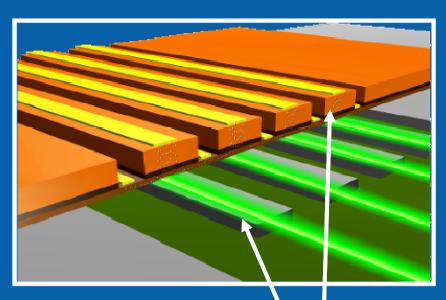
7) The light is coupled into the silicon waveguide which forms the laser cavity. Laser light emanates from the device.





Hybrid Silicon Laser

How we create a laser in silicon



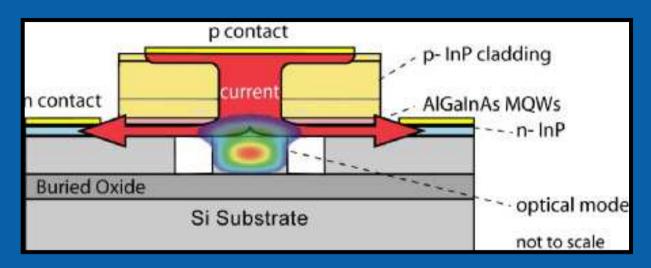
The Indium Phosphide emits the light into the silicon waveguide

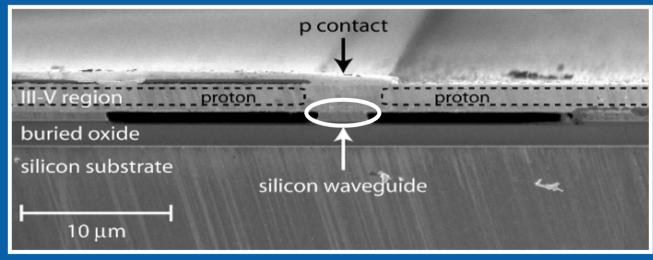
The silicon acts as laser cavity:

- Silicon waveguide routes the light
- End Facets are reflectors/mirrors
- Light bounces back and forth and get amplified by InP based material



Hybrid Laser Structure



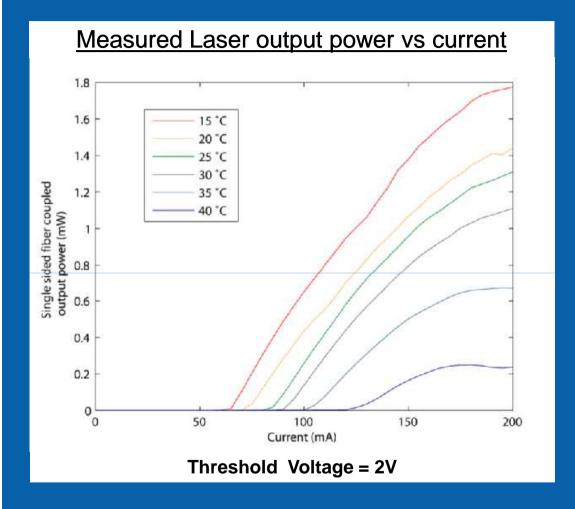


SEM (Scanning Electron Microscope) Photograph





First Electrically Pumped CW Lasing



Threshold Current

• At 65 mA with plans to get to \sim 20 mA

Output power

• At 1.8 mW, Good for optical interconnects

Temperature

 Operating at 40 C with plans for > 70 C

Initial testing shows good performance





Electrically Pumped Laser Wavelength

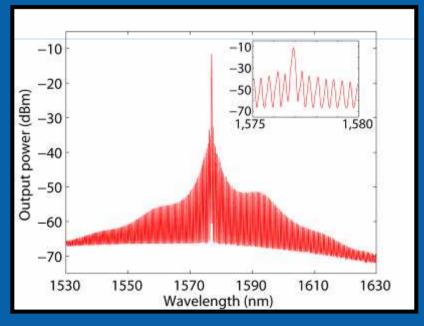
• 7 Hybrid Silicon Lasers

- All fabricated with a single bond step
- Up to 36 lasers are on one die

Lasing Output at 1577nm

 This is adjustable via modifying the silicon waveguides



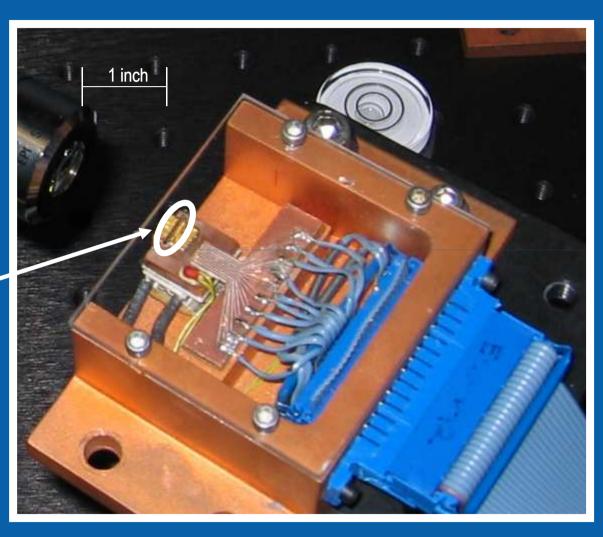






Silicon Hybrid Laser

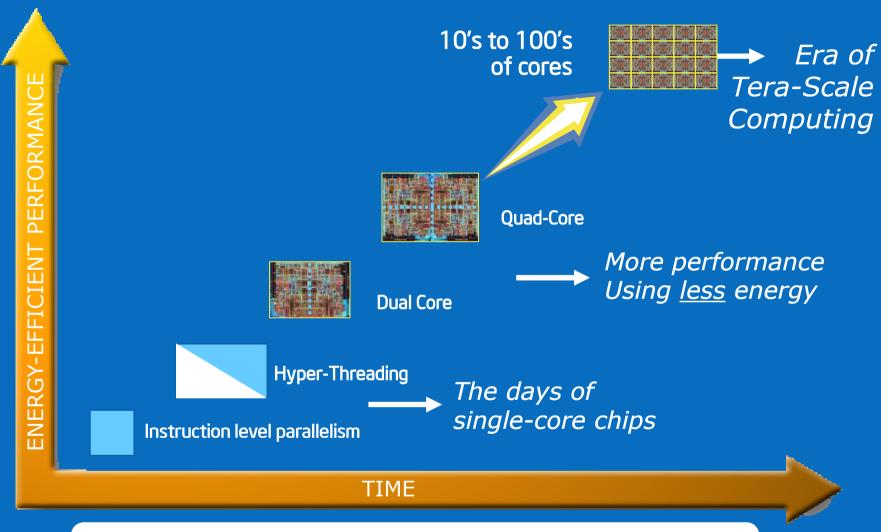








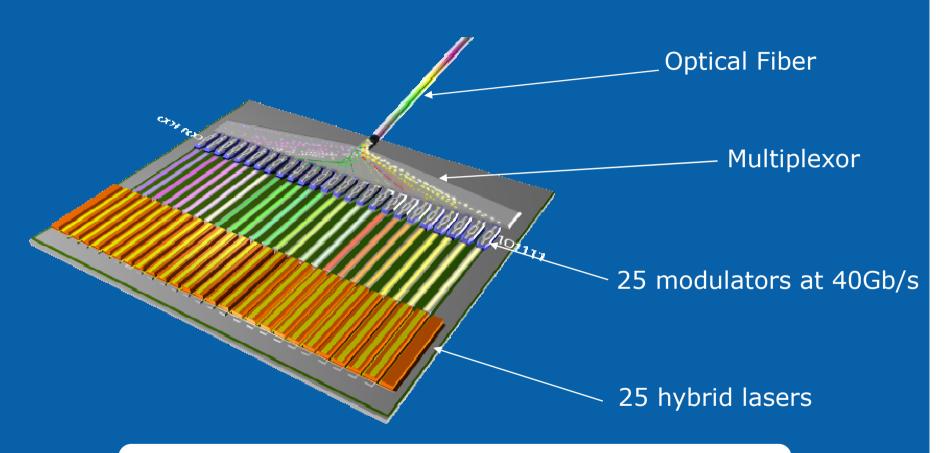
Tera-leap to Parallelism:



All this compute capability may require high speed optical links



High Integration

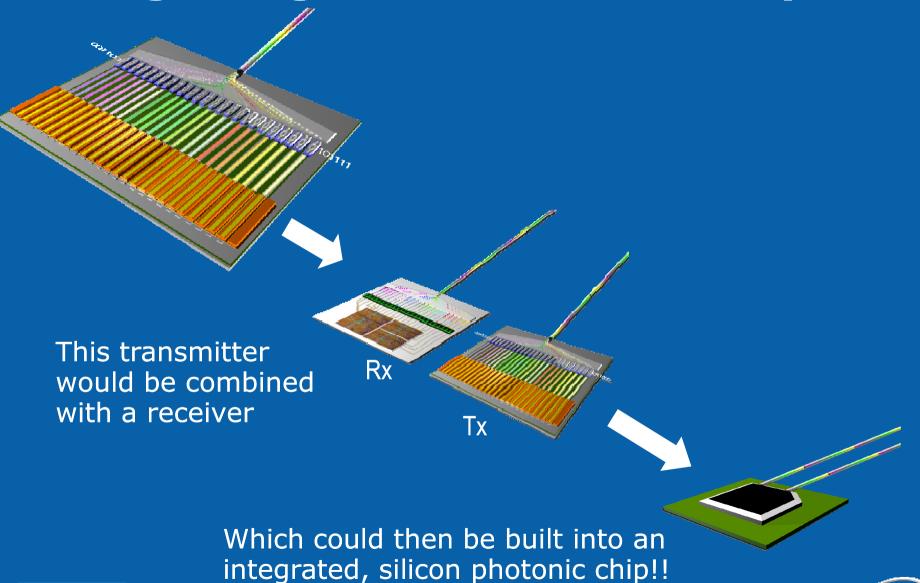


An future integrated terabit per second optical link on single chip





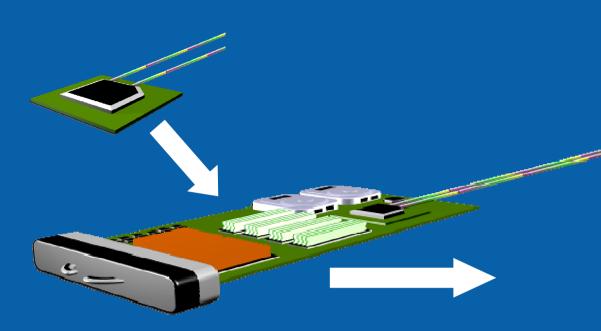
Integrating into a Tera-scale System



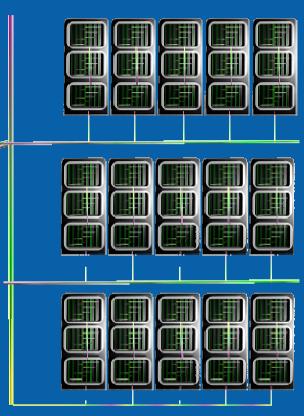




Integrating into a Tera-scale System



This integrated silicon photonic chip could then be integrated into computer boards



And this board could be integrated into a Tera-sca system





Summary

- Research Breakthrough: 1st Electrically pumped Hybrid Silicon Laser
 - A joint collaboration between UCSB and Intel Corporation
 - Combines the light emitting capabilities of Indium phosphide with the high volume, low cost capabilities of silicon
 - Addresses one of the last major hurdle to silicon photonic chips

Vision:

- Build chips containing 10 to 100s of Hybrid Silicon Lasers
- Built using high-volume, low cost manufacturing processes
- Enables terabit optical links

Background

- Silicon is a poor light emitter while Indium phosphide based materials are great light emitters
- However, Indium phosphide lasers are expensive to manufacture
- Novel design combined with a manufacturing process where a unique "glass glue" was used to bond the two materials together









Acknowledgements: UCSB and Professor Bowers would like to thank Jag Shah and DARPA for funding some of this research.



